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(54) **SILICATE PRODUCT AND STRENGTHENING METHOD THEREOF**

SILIKATPRODUKT UND VERSTÄRKUNGSVERFAHREN DAFÜR

PRODUIT DE SILICATE ET PROCÉDÉ DE RENFORCEMENT ASSOCIÉ

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Description**Technical Field**

- 5 **[0001]** The present invention relates to the field of silicate articles and the manufacture thereof and in particular relates to a glass plate, especially a glass cover plate used for display devices.

Background Art

- 10 **[0002]** With the rapid development of modern technologies, the touch screen has become the first choice in many electronic display products. A cover plate glass as the outermost layer of a touch screen is one of key materials for the touch screen. In recent years, electronic display products have been required to be lightweight and thin; therefore, the cover plate glass for protecting electronic display products is also gradually thinning.
- 15 **[0003]** However, when the cover plate glass is made thin in thickness, the strength thereof is also reduced, and the cover plate glass itself may sometimes be broken, or affected by cracks that would lead to slow cracking, due to dropping and the like during use or carrying; in addition, during long-term use, there may be scratches on the surface, and if the scratches are relatively deep, slow cracking of the glass also tends to occur.
- [0004]** Even in the case of chemically strengthened glass cover plates, cracking may also sometimes occur, or slow cracking starts from a scratch that has penetrated the layer of compressive stress.
- 20 **[0005]** CN 105102394 A discloses a glass plate and a manufacturing method thereof; however, it focuses on suppressing the warpage of the glass plate after chemical strengthening, without considering the matching among the components and the influence of the chemical strengthening process on the strength and the crack resistance.
- [0006]** CN 102639457 A discloses a glass plate and a manufacturing method thereof, wherein it focuses on suppressing the dissolution of Na^+ to the surface, thereby suppressing peeling of an anti-reflection film or a transparent conductive film
- 25 on a glass surface, resulting in a glass plate that is excellent in weather resistance; however, the matching among the components and the influence of the chemical strengthening process on the strength and the crack resistance are not considered.
- [0007]** The documents US 2015/044473 A1, WO 2015/147092 A1 and US 2016/221863 A1 describe glass compositions.
- 30 **[0008]** Therefore, there is a need to develop a glass cover plate that is resistant to rapid cracking and slow cracking.
- [0009]** In addition, the chemical resistance of the glass plate in the prior art is also unsatisfactory, so that the glass plates may be corroded by acid excessively fast during chemical thinning procedure, which tends to cause uneven corrosion, easily forming tiny defective dots or grooves on the surface of the glass, resulting in a decrease in the surface compressive stress value, which tends to cause cracks.
- 35 **[0010]** The inventors of the present application found that the strength of the glass cover plate can be remarkably improved by controlling the respective components of the glass and the contents thereof to satisfy a specific matching relationship, and this can not only prevent rapid cracking of the glass cover plate but also can prevent slow cracking thereof effectively.
- [0011]** Furthermore, the inventors have surprisingly found that although increasing the compressive stress value and the thickness of the layer of compressive stress can enhance the strength of the glass to prevent the glass being rapidly
- 40 cracked after collision, if the compressive stress and the depth of the layer of compressive stress are increased blindly, spontaneous burst or slow cracking may easily occur after collision or scratching; in addition, the inventors have surprisingly found that such spontaneous burst or slow cracking after collision can be effectively prevented by further controlling the tendency of the compressive stress value to change with depth and the depth of the layer of compressive stress.
- 45

Summary of the Invention

- 50 **[0012]** An objective of the present invention is to provide a glass composition and a glass plate, which can solve the problem that glass plates would undergo rapid cracking and spontaneous burst after collision, or slow cracking after collision or scratching in the prior art.
- [0013]** In order to achieve the above-mentioned objective, the present invention provides a glass composition comprising SiO_2 , Al_2O_3 , Na_2O , K_2O , MgO and ZrO_2 , wherein the content of Al_2O_3 is 15-28 parts by weight, the content of Na_2O is 13-25 parts by weight, the content of K_2O is 6-15 parts by weight, the content of MgO is 7-16 parts by weight, and the content of ZrO_2 is 0.1-5 parts by weight, relative to 100 parts by weight of SiO_2 .
- 55 and M is 5-13, as calculated by the following formula (1):

$$M = P_1 * \text{wt}(\text{Na}_2\text{O}) + P_2 * \text{wt}(\text{K}_2\text{O}) + P_3 * \text{wt}(\text{MgO}) + P_4 * \text{wt}(\text{ZrO}_2) - P_5 * \text{wt}(\text{Al}_2\text{O}_3) * \text{wt}(\text{Al}_2\text{O}_3) \quad (1)$$

wherein wt(Na₂O) represents the part by weight of Na₂O relative to 100 parts by weight of SiO₂,
 wt(K₂O) represents the part by weight of K₂O relative to 100 parts by weight of SiO₂,
 wt(MgO) represents the part by weight of MgO relative to 100 parts by weight of SiO₂,
 wt(ZrO₂) represents the part by weight of ZrO₂ relative to 100 parts by weight of SiO₂, and
 wt(Al₂O₃) represents the part by weight of Al₂O₃ relative to 100 parts by weight of SiO₂.

[0014] In the formula, P₁ has a value of 0.53, P₂ has a value of 0.153, P₃ has a value of 0.36, P₄ has a value of 0.67, and P₅ has a value of 0.018.

[0015] Preferably, the value of M is 6-10, further preferably 6.5-9, and further preferably 7-8.

[0016] Preferably, the content of Al₂O₃ is 18-25 parts by weight, the content of Na₂O is 17-23 parts by weight, the content of K₂O is 7-12 parts by weight, the content of MgO is 8-14 parts by weight, and the content of ZrO₂ is 0.8-2 parts by weight, relative to 100 parts by weight of SiO₂.

[0017] Preferably, the content of Al₂O₃ is 22 parts by weight, the content of Na₂O is 19 parts by weight, the content of K₂O is 9 parts by weight, the content of MgO is 12 parts by weight, and the content of ZrO₂ is 1.4 parts by weight, relative to 100 parts by weight of SiO₂.

[0018] Preferably, the glass composition of the present invention further comprises a certain amount of SrO, the content of SrO being 0-3 parts by weight, preferably less than 0.6 parts by weight, relative to 100 parts by weight of SiO₂.

[0019] Preferably, the glass composition of the present invention further comprises BaO and CaO, the content of BaO being 0-2 parts by weight, preferably less than 0.5 parts by weight, and the content of CaO being 0-2 parts by weight, preferably less than 0.5 parts by weight, relative to 100 parts by weight of SiO₂.

[0020] Preferably, the glass composition of the present invention has a 10% HF acid/20°C/20 min corrosion amount of less than 38 mg/cm².

[0021] Preferably, the glass composition of the present invention has a Young's modulus of higher than 65 GPa, further preferably higher than 75 GPa.

[0022] The present invention further provides a glass plate made from the glass composition of the present invention.

[0023] Furthermore, the ratio of a surface compressive stress value at a depth of 3 μm of the glass plate of the present invention to that at a depth of 7 μm, and the thickness of a layer of compressive stress are calculated by the following formula (2), and the resulting value of the crack resistance factor K should be less than 8.

$$K = Q_1 \cdot (x/y)^2 + Q_2 \cdot (x/y) - Q_3 \cdot d/10 \quad (2)$$

wherein x is the surface compressive stress value at a depth of 3 μm of the glass, and y is the surface compressive stress value at a depth of 7 μm of the glass, in unit of MPa; and d represents the thickness of a layer of compressive stress, in unit of μm;

wherein Q₁ has a value of 3.5, Q₂ has a value of 1.8, and Q₃ has a value of 0.12.

[0024] Preferably, the crack resistance factor K is less than 7.7, further preferably less than 7.3.

[0025] Preferably, the glass plate has a 10% HF acid/20°C/20 min corrosion amount of less than 38 mg/cm².

[0026] Preferably, the glass plate has a Young's modulus of higher than 65 GPa, further preferably higher than 75 GPa.

[0027] The present invention further provides a method for preparing a chemically strengthened glass plate, comprising manufacturing a glass composition into a plate-shaped article, and chemically strengthening the plate-shaped article.

[0028] During the chemical strengthening treatment, the temperature of a molten salt is 380°C-450°C, preferably 390°C-420°C, and more preferably 400°C, and the immersion time is 0.3-9 hours, preferably 1-8 hours, further preferably 2-7 hours, further preferably 3-6 hours, and more preferably 4-5 hours.

[0029] Preferably, ultrasonic vibration is added during the chemical strengthening.

[0030] The ultrasonic wave has an average acoustic energy density of 50-60 W/L and an ultrasonic frequency of 25-40 kHz.

[0031] The temperature of the ultrasonic treatment is 380°C-425°C, preferably 390°C-410°C, and more preferably 400°C; and the treatment time is 10-80 min, preferably 15-50 min, and more preferably 20-40 min.

[0032] Preferably, the ultrasonic treatment is carried out at intervals, wherein the time interval between ultrasonic treatments is 1-40 min, preferably 3-35 min, and more preferably 5-20 min; and the ultrasonic treatment time each time is 10-80 min, preferably 15-50 min, and more preferably 20-40 min.

[0033] Further preferably, while performing the chemical strengthening with ion exchange, microwave radiation is applied to the surface of the glass, further preferably performed alternately with the ultrasonic treatment.

[0034] The frequency range of the microwave is 1.1-6.2 GHz, preferably 2.6-4.6 GHz, more preferably 3.0-4.0 GHz, and

most preferably 3.3-3.5 GHz.

[0035] The duration of application of the microwave is 5-60 min, preferably 10-40 min, and most preferably 12-25 min.

[0036] The time interval of application of the microwave is 2-30 min, preferably 5-20 min, and more preferably 7-15 min; and the duration of application of the microwave each time is 5-60 min, preferably 10-40 min, and most preferably 12-25 min.

[0037] The glass plate of the present invention can be used for flat panel displays.

[0038] The present invention further provides a flat panel display made from the glass plate of the present invention.

[0039] The inventors of the present invention surprisingly found, by means of mathematical fitting, that the effect of each component in the glass on the physical and chemical properties of the glass shows a special law; and where the contents of the components other than silicon oxide change linearly, since the coefficients for the contents of these components are different, the influences thereof on the value of M in formula (1) are different, and accordingly, the change in the value of M is presented as a curve, that is to say, there is an optimal point value. When the content of each component further satisfies the range of the value of M as shown in formula (1), the Young's modulus, surface compressive stress value, crack resistance and chemical resistance of the glass plate, as measured upon testing, are optimized, and either an excessively large value or an excessively small value of M may result in a decrease in the above-mentioned properties of the glass plate.

[0040] For example, the inventors of the present application have surprisingly found that when the content of Al_2O_3 is 20 parts by weight, the content of Na_2O is 19 parts by weight, the content of K_2O is 9 parts by weight, the content of MgO is 10 parts by weight, and the content of ZrO_2 is 0.9 parts by weight, relative to 100 parts by weight of SiO_2 , the value of M is 8.5, and at this point, the glass has the optimal resistance to cracking and slow cracking, and such an abrupt change in performance is beyond the general expectations of a person skilled in the art. If an ultrasonic treatment and a microwave treatment are employed during the chemical strengthening, and the treatment conditions thereof are optimized (see Example 8 and Example 9), the resulting effect of resistance to cracking and slow cracking would be unpredictable to a person skilled in the art.

[0041] The inventors of the present application found that the surface stress value at a certain depth of the glass and the thickness of a layer of stress thereof are calculated according to the formula (2), and when the calculated value of the crack resistance factor K is less than 8, the glass plate of the present invention has a higher Young's modulus, a preferred compressive stress value distribution, and a preferred stress layer thickness. If the compressive stress value changes too rapidly with depth, the calculated value of the crack resistance factor K will be too large, and which means that the glass plate is prone to spontaneous burst during use and also slow cracking after collision.

[0042] Furthermore, the glass plate of the present invention has a higher Young's modulus and a stronger chemical corrosion resistance.

[0043] According to the present invention, the above-mentioned method for preparing the glass plate may involve using a conventional common means, which may be, for example, an overflow down-draw process, a slot down-draw process, a redraw process, a float process, etc.

[0044] It is easy to allow the value of the crack resistance factor K as defined by the present invention to be less than 8 by the following chemical strengthening process, specifically as follows:

with regard to the chemical strengthening process, common means in the art may be employed as long as Li_2O and Na_2O on the surface layer of the glass plate can be ion-exchanged with Na_2O and K_2O in a molten salt, for example, such a method may be employed, which involves immersing a glass plate in a hot molten salt of sodium nitrate (NaNO_3), a molten salt of potassium nitrate (KNO_3), or a mixed molten salt thereof. Optionally, the glass plate can be first immersed in a nitrate including NaNO_3 , and then immersed in a nitrate including KNO_3 .

[0045] During the chemical strengthening, although stirring can also accelerate the movement of ions, a stagnant region tends to be present during stirring, and the speed is not easy to control. Preferably, an ultrasonic vibration is added during the chemical strengthening to improve the movement of relevant ions (e.g., K^+) in the ion-exchange liquid. Since the relevant ions (e.g., K^+) are displaced into the surface of the glass, these ions (e.g., K^+) near the surface of the glass are deficient with a decreased concentration; the addition of the ultrasonic vibration can make a rapid compensation for these ions (e.g., K^+) near the surface of the glass, meanwhile enabling the ions exchanged out (e.g., Na^+) to leave rapidly, thereby reducing the concentration of these ions (e.g., Na^+) near the surface of the glass, so that the speed of the ion exchange is increased and the extent of the ion exchange is more thorough.

[0046] Further preferably, after one ultrasonic treatment is done, there is a time interval before a second ultrasonic treatment; and by means of such a treatment at intervals, the molten salt liquid tends to be stabilized during the interval, and a certain period of time is provided for the alkali metal ion exchange on the surface of the glass accordingly.

[0047] Further preferably, it may also be possible to apply microwave radiation to the surface of the glass. When the microwave radiation is applied to the surface of the glass, the alkali ion components in the glass vibrate in response to the microwave, thereby slightly loosening intermolecular bonding structures of the glass and generating heat. Furthermore, ions with large particle diameters in the ion exchange liquid also vibrate due to the microwave, thereby increasing the activity of the ions and generating heat; accordingly, the ion exchange reaction of the glass can also be facilitated, thereby

shortening the time of the ion exchange of the glass. Preferably, the microwave is also used intermittently; and further preferably, the ultrasonic wave and the microwave are used in an alternating manner. By means of microwave radiation, the depth of the ion exchange of the glass can also be increased.

[0048] For example, provided that the other conditions of the chemical strengthening treatment are the same, when a soda lime silicate glass is immersed in a potassium nitrate solution at 400°C for 3.6 hours, during which microwave radiation is applied for 20 min, the soda lime silicate glass can have a compressive stress of 400-500 MPa and a thickness of layer of compressive stress in the range of 20-25 μm ; however, the soda lime silicate glass generally has a compressive stress of 300-400 MPa and a thickness of layer of compressive stress in the range of 10-20 μm without using the microwave radiation. When an alkali aluminosilicate glass is immersed in a potassium nitrate solution at 410°C for 3.5 hours, during which microwave radiation is applied for 20 min, the alkali aluminosilicate glass has a compressive stress of 670-710 MPa and a thickness of layer of compressive stress in the range of 60-65 μm . However, it needs about 4.6 hours to achieve the same compressive stress value and the same depth of layer of compressive stress without using microwave radiation.

[0049] By using an ultrasonic wave and/or a microwave during the chemical strengthening, as described in the present application, it is easier to make the value of the crack resistance factor K of a prepared glass plate be less than 8.

[0050] The present invention is further described below by means of examples, but the present invention is not limited thereto. In the following examples of the present invention, the reagents used are all commercially available products.

Detailed Description of Embodiments

[0051] Specific embodiments of the present invention are described in detail below. It should be understood that the specific embodiments described herein are merely illustration and explanation of the present invention and are not intended to limit the present invention.

[0052] Tables 1 and 2 show the components of glasses and the contents thereof, as well as the process parameters of the preparation of the glass in Examples 1-10 and Comparative Examples 1-5.

[0053] There is no particular limitation on the preparation of molten glass, and hereinafter the preparation steps are described taking Example 1 as an example as follows:

Appropriate amounts of various raw materials are mixed, placed in a crucible made from platinum and heated to about 1,400°C to 1,600°C to melt them, and after being defoamed and homogenized, the mixture is poured into a mould and annealed to obtain a glass block. The glass block is then cut and ground to obtain a glass plate having a thickness of 0.5 mm, and the glass plate is cut into a desired size (65 mm*135 mm).

[0054] The glass plate is immersed in a molten salt of potassium nitrate (KNO_3), wherein the temperature of the molten salt and the immersion time are specifically shown in the table; and the specific parameters for the ultrasonic treatment and the microwave treatment are also detailed in the table.

[0055] The compressive stress S (unit: MPa) and the thickness t (unit: μm) of the layer of compressive stress are measured by using methods known in the art. Such methods include, but are not limited to, measuring surface stress (FSM) using, for example, FSM-6000 manufactured by Luceo Co., Ltd. (Tokyo, Japan) or a similar commercial instrument, and in the examples and comparative examples in the present invention, the compressive stress and the depth of layer of compressive stress are measured by using FSM-6000 manufactured by Luceo Co., Ltd. (Tokyo, Japan), specifically by means of methods as described in ASTM 1422C-99 entitled "Standard Specification for Chemically Strengthened Flat Glass", and as described in ASTM 1279.19779 entitled "Standard Test Method for Non-Destructive Photoelastic Measurement of Edge and Surface Stresses in Annealed, Heat-Strengthened, and Fully Tempered Flat Glass". The measurement of surface stress relies on the accurate measurement of stress optical coefficient (SOC), which is related to the birefringence of a stress-induced glass.

[0056] The instrument has the following parameters:

Measurement range: 0-1000 MPa

Measurement accuracy: ± 20 MPa

Measurement range (depth of layer of stress): 10-100 μm

Accuracy (depth of layer of stress): ± 5 μm

Light source: High-brightness LED light source produced by Orihara corporation

Measurement shape: flat glass, 10 $\times$ 10 mm or larger

Prism: size = 12*7 mm RI = 1.72/590 nm

During measurement, the two surfaces of the glass plate are subjected to mirror polish, grinding or etching to eliminate 3 μm of the surfaces, and after measurement, the glass is further polished, ground or etched by 4 μm .

[0057] A falling ball used in a falling ball impact test is made from stainless steel, and has a mass of 130 g and a diameter of 31.5 cm. During testing, the glass is placed on a bakelite plate mould made from a phenolic resin material, as

conventionally used in the art, the above-mentioned steel ball is dropped from different heights, and by dropping ball multiple times, a simple average value of the ball drop height at which cracking occurs is calculated, as a crack height.

[0058] With regard to the resistance of the glass to slow cracking, if the glass plate is left to stand, the time consumed for observing the slow cracking thereof is too long; therefore, a glass plate in which a microcrack appears is placed on a vibrator to accelerate the cracking thereof for the purpose of testing. The change in the length of the crack is observed, and the times (min) required for the crack reaching 10 mm, 15 mm and 20 mm are recorded.

[0059] The vibrator may be any commercially available vibrator as long as the same vibrator and operating parameters are used in the examples and comparative examples. For example, a pneumatic vibrator (QSE small environmentally friendly vibrator, such as QSE-20, with a vibration force of 10 N, a frequency of 7-70 Hz, a noise of 25 db, and a working temperature of -10°C to 70°C) produced by Yantai JieShun Pneumatic Equipment Manufacturing Co., Ltd is used in the examples and comparative examples in the present invention, and during operation, the flat glass to be tested is placed above the vibrator.

Table 1

	Example 1	Example 2	Example 3	Example 4	Example 5	Example 6	Example 7
SiO ₂	100	100	100	100	100	100	100
Al ₂ O ₃	17	18	25	25	15	20	22
Na ₂ O	15	16	22	24	13	14	23
K ₂ O	7	9	8	8	6	10	7
MgO	8	10	9	7	9	8	9
CaO	0.5	0	0.4	0	0.5	0.1	0.2
ZrO ₂	5	3	0.8	0.5	3.2	3	2
BaO	0.5	0.7	0.6	0	0.8	0.9	0.3
SrO	0.5	0	0.6	0	0.7	0.8	0.5
M (P ₁ =0.53, P ₂ =0.153,	10.0	9.6	5.4	5.5	9.1	6.6	9.1
P ₃ =0.36, P ₄ =0.67, and P ₅ =0.018)							
The sur- face com- pressi ve stress va- lue at a depth of 3 μm, S (MPa)	689	672	670	660	650	580	560
The sur- face com- pressi ve stress va- lue at a depth of 7 μm, S (MPa)	595	580	578	573	560	450	430

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(continued)

		Example 1	Example 2	Example 3	Example 4	Example 5	Example 6	Example 7
5	Depth of layer of compressive stress, t (μm)	37.8	39.2	38.8	38.3	36.7	31.5	30.8
10	K (Q ₁ =3.5, Q ₂ =1.8, and Q ₃ =0.12)	6.3	6.3	6.5	6.7	6.4	7.8	7.9
15	Ultrasonic treatment acoustic energy density (W/L)	55	57	55	50	60	--	--
20	Ultrasonic frequency (kHz)	30	27	30	25	40	--	--
25	Ultrasonic treatment temperature (°C)	400	390	420	380	425	--	--
30	Ultrasonic treatment time (min)	25	20	22	10	8	--	--
35	Time interval (min)	12	18	15	5	12	--	--
40	Microwave treatment (GHz)	3.0	3.5	3.3	2.6	3.0	--	--
45	Microwave treatment time (min)	15	12	17	13	10	--	--
50	Time interval (min)	--	10	15	5		--	--
55	Remarks	After	After	After	After	After	--	--

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(continued)

	Example 1	Example 2	Example 3	Example 4	Example 5	Example 6	Example 7
5	ultrasonic treatment, there is a time interval of 12 min before microwave treatment, and after the microwave treatment, the next round of ultrasonic treatment is carried out.	ultrasonic treatment, there is a time interval of 18 min before microwave treatment, and after the microwave treatment, there is a time interval of 10 min before the next round of ultrasonic treatment.	ultrasonic treatment, there is a time interval of 15 min before microwave treatment, and after the microwave treatment, there is a time interval of 15 min before the next round of ultrasonic treatment.	ultrasonic treatment, there is a time interval of 5 min before microwave treatment, and after the microwave treatment, there is a time interval of 5 min before the next round of ultrasonic treatment.	ultrasonic treatment, there is a time interval of 12 min before microwave treatment, and after the microwave treatment, the next round of ultrasonic treatment is carried out.		
10							
15							
20							
25							
	Molten salt temperature, immersion time	420°C, 4 h	420°C, 4 h	420°C, 4 h	400°C, 4.5 h	410°C, 3 h	410°C, 3 h
30	Chemical resistance	34	35	32	30	30	36
	to 10% HF acid/20°C/20 min (mg/cm ²)						
35	Young's modulus (GPa)	86.5	89.8	79.8	75.4	74.8	68.4
40	Average ball drop height at which cracking occurs (cm) (the falling ball has a mass of 130 g, and a diameter of 31.5 cm)	52	54	53	50	49	42
45							
50							
55	Vibration test (the time required for crack reaching 10 mm, 15 mm and 20 mm,	19	17	18	16	14	11
		31	27	30	26	22	19
		46	39	45	38	37	30

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(continued)

	Example 1	Example 2	Example 3	Example 4	Example 5	Example 6	Example 7
5	respectivel y (min))						

Table 2

10		Example 8	Example 9	Example 10	Example 11	Compara tive Example 1	Compara tive example 2	Compara tive example 3	Compara tive Example 4
15	SiO ₂	100	100	100	100	100	100	100	100
	Al ₂ O ₃	20	20	22	22	15	21	20	22
	Na ₂ O	19	19	18	18	24	13	13	17
	K ₂ O	9	9	10	10	9	7	6	6
20	MgO	10	10	9	9	9	7	8	7
	CaO	0	0.6	0.3	0	1	0.6	0.2	0.2
	ZrO ₂	0.9	0.9	0.7	0.7	3	2	0.6	1
25	BaO	0	0.7	0.9	0	0.9	0.8	0.9	0.9
	SrO	0	1.2	1	0	2	1.0	1.1	1.1
30	M (P ₁ =0.53, P ₂ =0.153, P ₃ =0.36, P ₄ =0.67, and P ₅ =0.018)	8.5	8.5	6.0	6.0	15.3	3.9	3.9	4.4
35	The sur- face com- pressi ve stress va- lue at a depth of 3 μm, S (MPa)	714	690	650	640	560	530	540	590
40									
45	The sur- face com- pressi ve stress va- lue at a depth of 7 μm, S (MPa)	625	608	536	545	400	390	400	445
50									
55	Depth of layer of compressi ve stress, t (μm)	45.9	44.8	35.8	36.1	22.5	21.5	25.8	28.5

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(continued)

5		Example 8	Example 9	Example 10	Example 11	Compara tive Example 1	Compara tive example 2	Compara tive example 3	Compara tive Example 4
10	K ($Q_1=3.5$, $Q_2=1.8$, and $Q_3=0.12$)	6.1	6.0	6.9	6.5	9.1	8.7	8.5	8.2
15	Ultrasonic treatment acoustic energy density (W/L)	55	56	56	55	--	--	--	55
20	Ultrasonic frequency (kHz)	30	32	32	30	--	--	--	30
25	Ultrasonic treatment temperatur e (°C)	400	410	410	400	--	--	--	400
30	Ultrasonic treatment time (min)	35	20	25	15	--	--	--	25
35	Time inter- val (min)	10	12	12	10	--	--	--	9
40	Microwav e treatment (GHz)	3.0	3.5	3.5	3.0	--	--	--	3.0
45	Microwav e treatment time (min)	15	10	10	20	--	--	--	10
50	Time inter- val (min)	8	9	12	10	--	--	--	8
	Remarks	After ultra- soni c treatment , there is a time inter- val of 10 min before microwa ve treatment	After ultra- soni c treatment , there is a time inter- val of 12 min before microwa ve treatment	After ultra- soni c treatment , there is a time inter- val of 12 min before microwa ve treatment	After ultra- soni c treatment , there is a time inter- val of 10 min before microwa ve treatment	--	--	--	After ul- trasoni c treatmen t, there is a time in- terval of 9 min be- fore mi- crowa ve treatmen t, and

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(continued)

5		Example 8	Example 9	Example 10	Example 11	Comparative Example 1	Comparative example 2	Comparative example 3	Comparative Example 4
10		, and after the microwave treatment, there is a time interval of 8 min before the next round of ultrasonic treatment.	, and after the microwave treatment, there is a time interval of 9 min before the next round of ultrasonic treatment.	, and after the microwave treatment, there is a time interval of 12 min before the next round of ultrasonic treatment.	, and after the microwave treatment, there is a time interval of 10 min before the next round of ultrasonic treatment.				after the microwave treatment, there is a time interval of 8 min before the next round of ultrasonic treatment.
15									
20									
25	Molten salt temperature, immersion time	420°C, 5 h	400°C, 4.5 h	400°C, 4.5 h	400°C, 4.5 h	400°C, 4.5 h	400°C, 4.5 h	420°C, 3 h	420°C, 3 h
30	Chemical resistance to 10% HF acid/20°C/20 min (mg/cm ²)	32	33	33	30	48	55	47	41
35	Young's modulus (GPa)	76.4	75.6	74.8	75	61.7	60.8	62.5	65.5
40	Average ball drop height at which cracking occurs (cm) (the falling ball has a mass of 130 g, and a diameter of 31.5 cm)	55	57	54	51	30	31	32	36
45									
50	Vibration	20	21	18	19	4	5	3	8
55	test (the time required for crack reaching 10 mm, 15 mm and 20 mm, respectively (min))	35	37	32	33	12	13	13	18
		48	49	43	44	20	17	21	27

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Table 3

	Example 12	Example 13	Example 14	Example 15	Comparative Example 5	Comparative Example 6	Comparative Example 7
5	SiO ₂	100	100	100	100	100	100
	Al ₂ O ₃	28	18	27	14	29	14
	Na ₂ O	25	17	23	12	28	6.8
10	K ₂ O	15	12	14	5	18	18
	MgO	11	11	16	6	6.5	6.5
	CaO	1.5	1.2	0.7	2.5	2.2	2.8
15	ZrO ₂	0.1	3.8	0.2	6	7.8	7.8
	BaO	0.4	0.2	1.2	2.2	2.4	2.6
	SrO	0.2	0.1	3	3.2	3.3	3.5
20	M (P ₁ =0.53, P ₂ =0.153, P ₃ =0.36, P ₄ =0.67, and P ₅ =0.018)	5.5	11.5	7.1	7.2	9.7	10.4
25	The surface compressive stress value at a depth of 3 μm, S (MPa)	685	668	675	670	560	584
30							
35	The surface compressive stress value at a depth of 7	590	577	582	563	418	428
40	μm, S (MPa)						
45	Depth of layer of compressive stress, t (μm)	36.8	35.2	34.8	38.6	26.6	24.3
50	K (Q ₁ =3.5, Q ₂ =1.8, and Q ₃ =0.12)	6.4	6.4	6.4	6.6	8.4	8.7
55	Ultrasonic treatment acoustic energy density (W/L)	55	57	55	50	55	50

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(continued)

	Example 12	Example 13	Example 14	Example 15	Comparative Example 5	Comparative Example 6	Comparative Example 7
Ultrasonic frequency (kHz)	30	27	30	25	30	25	27
Ultrasonic treatment temperature (°C)	400	390	420	380	400	380	390
Ultrasonic treatment time (min)	25	20	22	10	20	10	20
Time interval (min)	12	18	15	5	12	5	18
Microwave treatment (GHz)	3.0 GHz	3.5 GHz	3.3 GHz	2.6 GHz	3.0 GHz	2.6 GHz	3.5 GHz
Microwave treatment time (min)	15	12	17	13	15	13	12
Time interval (min)	10	10	15	5	10	5	10
Remarks	After ultrasonic treatment, there is a time interval of 12 min	After ultrasonic treatment, there is a time interval of 18 min	After ultrasonic treatment, there is a time interval of 15 min	After ultrasonic treatment, there is a time interval of 5 min	After ultrasonic treatment, there is a time interval of 12 min	After ultrasonic treatment, there is a time interval of 5 min	After ultrasonic treatment, there is a time interval of 18 min
	before microwave treatment, and after the microwave treatment, the next round of ultrasonic treatment is carried out.	before microwave treatment, and after the microwave treatment, there is a time interval of 10 min before the next round of ultrasonic treatment.	before microwave treatment, and after the microwave treatment, there is a time interval of 15 min before the next round of ultrasonic treatment.	before microwave treatment, and after the microwave treatment, there is a time interval of 5 min before the next round of ultrasonic treatment.	before microwave treatment, and after the microwave treatment, the next round of ultrasonic treatment is carried out.	before microwave treatment, and after the microwave treatment, there is a time interval of 5 min before the next round of ultrasonic treatment.	before microwave treatment, and after the microwave treatment, there is a time interval of 10 min before the next round of ultrasonic treatment.
Molten salt temperature, immersion time	410°C, 4 h	410°C, 4h	410°C, 4 h	420°C, 4.5 h	410°C, 4 h	420°C, 4 h	420°C, 4 h

55

(continued)

	Example 12	Example 13	Example 14	Example 15	Comparati ve Example 5	Comparati ve Example 6	Comparati ve Example 7
5							
10	Chemical resistance to 10% HF acid/20°C/ 20 min (mg/cm ²)	34	35	32	34	41	42
15	Young' s modulus (GPa)	79.1	76.8	79.8	75.4	66.2	65.6
20	Average ball drop height at which cracking occurs (cm) (the falling ball has a mass of 130 g, and a diameter of 31.5 cm)	49	44	48	50	38	38
25							
30	Vibration test (the time	13	15	13	14	8	6
		26	27	28	26	16	15
35	required for crack reaching 10 mm, 15 mm and 20 mm, respectivel y (min))	38	42	39	38	26	28

40 **[0060]** As shown in Tables 1-3, the contents of the various components of the glass compositions and the values of M thereof in Examples 1-5 and 8-15 fall within the ranges of the present invention. In contrast, although the contents of the various components of the glass composition in Comparative Example 4 fall within the ranges of the present invention, the value M thereof is out of the range of the present invention; and although the values of M of the glass compositions in Comparative Example 5-7 fall within the ranges of the present invention, the contents of the various components thereof

45 are out of the ranges of the present invention. In contrast, the glass products in Examples 1-5 and 8-15 are all superior to those in Comparative Examples 4-7 in terms of chemical resistance and Young's modulus, and also superior to those in Comparative Examples 4-7 in terms of the average height at which the glass plate cracks in the falling ball test, and the times required for crack reaching 10 mm, 15 mm and 20 mm, respectively, in the vibration test are longer than those in Comparative Examples 4-7, i.e., having a preferred resistance to slow cracking.

50 **[0061]** It can be seen that with respect to the cases where only the contents of the various components in the glass composition satisfy the ranges of the present invention or only the value of M satisfies the range of the present invention, the cases where the contents of the various components and the value of M both satisfy the ranges of the present invention can produce unexpected technical effects in terms of chemical resistance, Young's modulus, and crack resistance of the glass products.

55 **[0062]** Furthermore, it can be seen from Tables 1 and 2 that Examples 1-11, in which the contents of various components in the glass compositions satisfy the ranges of the present invention, the values of M satisfy a range of 5-13, and the values of the crack resistance factor K are less than 8, are superior to Comparative Examples 1-4 in terms of the chemical resistance and Young's modulus, and also superior to Comparative Examples 1-4 in terms of the average height at which

the glass plate cracks in the falling ball test, and the times required for crack reaching 10 mm, 15 mm and 20 mm, respectively, in the vibration test are longer than those in Comparative Examples 1-4, i.e., having a preferred resistance to slow cracking.

[0063] Further preferably, where the contents of various components satisfy the ranges of the present invention and the value of M satisfies the range of 5-13, if no ultrasonic treatment or ultrasonic and microwave treatment is applied during the chemical strengthening, the performances such as chemical resistance, Young's modulus, the height at which the glass plate cracks, times required for crack reaching certain lengths in the vibration test and the like are all inferior to those of a glass plate having been subjected to ultrasonic treatment or ultrasonic and microwave treatment during the chemical strengthening. For details, reference can be made to the data of Example 6 and Example 7, and the values of M therein are respectively 6.6 and 9.1, which satisfy the range of 5-13, but these examples are not subjected to ultrasonic and microwave treatment during the chemical strengthening; consequently, the values of the crack resistance factor K are relatively high, and are 7.8 and 7.9, respectively. The Young's moduli are 68.4 GPa and 67.4 GPa, respectively, which are lower than those in the other samples (Examples 1-5 and 8-11) which have been subjected to ultrasonic and microwave treatment during the chemical strengthening, but also higher than the values in Comparative Examples 1-4; the average heights at which the glass plate cracks in the falling ball test are slightly less than those in Examples 1-5 and 8-11, but higher than those in Comparative Examples 1-4; and the times required for crack reaching certain lengths in the vibration test are also shorter than those in Examples 1-5 and 8-11, but longer than those in Comparative Examples 1-4, that is to say, the resistance to slow cracking is worse than that in Examples 1-5 and 8-11, but superior to that in Comparative Examples 1-4.

[0064] For Comparative Example 4, the value of M is 4.4, which is not in the range of 5-13, but ultrasonic treatment and microwave treatment are carried out during the chemical strengthening; it can be seen by comparison that the surface compressive stresses values at 3 μm and 7 μm and the crack resistance factor K are both better than those in Comparative Examples 1-3, the chemical resistance thereof to 10% HF acid/20°C/20 min is 41 mg/cm², the Young's modulus is 65.5 GPa, and the ball drop height at which cracking occurs is 36 cm, which are all superior to the corresponding performances in Comparative Examples 1-3. In the vibration test, the times required for the crack reaching 10 mm, 15 mm and 20 mm, respectively, are 8 min, 18 min, and 27 min, respectively, which are all longer than those in Comparative Examples 1-3, that is to say, although the value of M does not satisfy the range of 5-13, the obtained glass plate sample can also have a relatively good resistance to slow cracking if the sample has been subjected to ultrasonic treatment and microwave treatment.

[0065] The preferred embodiments of the present invention have been described in detail above, but the present invention is not limited to the specific details in the above embodiments; various simple modifications can be made to the technical solutions of the present invention within the scope of the technical concept of the present invention, and these simple modifications all fall within the scope of protection of the present invention.

[0066] It is to be further noted that the specific technical features described in the above-mentioned specific embodiments may be combined in any suitable manner without contradiction. In order to avoid unnecessary repetition, the present invention will not be further described with regard to various possible combinations.

[0067] In addition, any combination of various embodiments of the present invention may be made as long as the combination does not depart from the concept of the present invention, and such a combination should also be regarded as the disclosure of the present invention.

Claims

1. A glass composition, comprising SiO₂, Al₂O₃, Na₂O, K₂O, MgO and ZrO₂,

wherein the content of Al₂O₃ is 15-28 parts by weight, the content of Na₂O is 13-25 parts by weight, the content of K₂O is 6-15 parts by weight, the content of MgO is 7-16 parts by weight, and the content of ZrO₂ is 0.1-5 parts by weight, relative to 100 parts by weight of SiO₂;
and wherein the glass composition has an M value of 5-13, as calculated by the following formula (1):

$$M = P_1 \cdot \text{wt}(\text{Na}_2\text{O}) + P_2 \cdot \text{wt}(\text{K}_2\text{O}) + P_3 \cdot \text{wt}(\text{MgO}) + P_4 \cdot \text{wt}(\text{ZrO}_2) - P_5 \cdot \text{wt}(\text{Al}_2\text{O}_3) \cdot \text{wt}(\text{Al}_2\text{O}_3) \quad (1)$$

wherein wt(Na₂O) represents the part by weight of Na₂O relative to 100 parts by weight of SiO₂,
wt(K₂O) represents the part by weight of K₂O relative to 100 parts by weight of SiO₂,
wt(MgO) represents the part by weight of MgO relative to 100 parts by weight of SiO₂,
wt(ZrO₂) represents the part by weight of ZrO₂ relative to 100 parts by weight of SiO₂, and
wt(Al₂O₃) represents the part by weight of Al₂O₃ relative to 100 parts by weight of SiO₂;

and wherein P_1 has a value of 0.53, P_2 has a value of 0.153, P_3 has a value of 0.36, P_4 has a value of 0.67, and P_5 has a value of 0.018.

2. The glass composition according to claim 1, wherein the value of M is 6-10, further preferably the value of M is 6.5-9, and further preferably 7-8.
3. The glass composition according to claim 1 or 2, wherein the content of Al_2O_3 is 18-25 parts by weight, the content of Na_2O is 17-23 parts by weight, the content of K_2O is 7-12 parts by weight, the content of MgO is 8-14 parts by weight, and the content of ZrO_2 is 0.8-2 parts by weight, relative to 100 parts by weight of SiO_2 .
4. The glass composition according to claim 1 or 2, wherein said glass composition further comprises a certain amount of SrO , the content of SrO being 0-3 parts by weight, preferably less than 0.6 parts by weight, relative to 100 parts by weight of SiO_2 .
5. The glass composition according to claim 1 or 2, wherein said glass composition further comprises BaO and CaO , the content of BaO being 0-2 parts by weight, preferably less than 0.5 parts by weight, and the content of CaO being 0-2 parts by weight, preferably less than 0.5 parts by weight, relative to 100 parts by weight of SiO_2 .
6. The glass composition according to claim 1, wherein said glass composition has a 10% HF acid/20°C/20 min corrosion amount of less than 38 mg/cm².
7. The glass composition according to claim 1, wherein said glass composition has a Young's modulus of higher than 65 GPa, further preferably higher than 75 GPa.
8. A glass plate, **characterized in that** said glass plate is made from the glass composition according to any one of claims 1 to 7.
9. The glass plate according to claim 8, wherein the ratio of a surface compressive stress value at a depth of 3 μm of said glass plate to that at a depth of 7 μm , and the thickness of a layer of compressive stress are calculated by the following formula (2), and the resulting value of the crack resistance factor K should be less than 8:

$$K = Q_1 * (x/y)^2 + Q_2 * (x/y) - Q_3 * d/10 \quad (2)$$

wherein x is the surface compressive stress value at a depth of 3 μm of the glass plate, and y is the surface compressive stress value at a depth of 7 μm of the glass plate, in unit of MPa; and d represents the thickness of a layer of compressive stress, in unit of μm ;

wherein Q_1 has a value of 3.5, Q_2 has a value of 1.8, and Q_3 has a value of 0.12.

10. The glass plate according to claim 9, wherein the value of K is less than 7.7, further preferably less than 7.3.
11. A method for preparing the glass plate according to any one of claims 8 to 10, **characterized in that** the glass composition according to any one of claims 1 to 7 is manufactured into a plate-shaped article and subjected to chemical strengthening,
 - wherein said chemical strengthening comprises immersing the plate-shaped article in a molten salt of a nitrate, optionally, immersing said plate-shaped article in a molten salt of sodium nitrate ($NaNO_3$), a molten salt of potassium nitrate (KNO_3), or a mixed molten salt thereof; optionally, first immersing said plate-shaped article in a molten salt of sodium nitrate ($NaNO_3$) and then immersing in a molten salt of potassium nitrate (KNO_3).
12. The preparation method according to claim 11, wherein during the chemical strengthening, the temperature of the molten salt is 380°C-450°C, preferably 390°C-420°C, and more preferably 400°C, and the immersion time is 0.3-9 hours, preferably 1-8 hours, further preferably 2-7 hours, further preferably 3-6 hours, and more preferably 4-5 hours.
13. The preparation method according to claim 12, wherein an ultrasonic treatment is added during the chemical strengthening.

14. The preparation method according to claim 13, wherein the ultrasonic wave in said ultrasonic treatment has an average acoustic energy density of 50-60 W/L and an ultrasonic frequency of 25-40 kHz.
15. The preparation method according to claim 13, wherein the temperature of said ultrasonic treatment is 380°C-425°C, preferably 390°C-410°C; and the treatment time is 10-80 min, preferably 15-50 min, and more preferably 20-40 min.
16. The preparation method according to claim 13, wherein said ultrasonic treatment is carried out at intervals, wherein the time interval between ultrasonic treatments is 1-40 min, preferably 3-35 min, and more preferably 5-20 min; and the ultrasonic treatment time each time is 10-80 min, preferably 15-50 min, and more preferably 20-40 min.
17. The preparation method according to claim 13, wherein while performing the chemical strengthening, microwave radiation is applied to the surface of the glass, preferably performed alternately with the ultrasonic treatment.
18. The preparation method according to claim 17, wherein the frequency range of the microwave is 1.1-6.2 GHz, preferably 2.6-4.6 GHz, more preferably 3.0-4.0 GHz, and most preferably 3.3-3.5 GHz.
19. The preparation method according to claim 17, wherein the duration of application of the microwave is 5-60 min, preferably 10-40 min, and most preferably 12-25 min, wherein the time interval of application of the microwave is 2-30 min, preferably 5-20 min, and more preferably 7-15 min; and the duration of application of the microwave each time is 5-60 min, preferably 10-40 min, and most preferably 12-25 min.

Patentansprüche

1. Eine Glaszusammensetzung, umfassend SiO_2 , Al_2O_3 , Na_2O , K_2O , MgO und ZrO_2 ,

wobei der Gehalt an Al_2O_3 15-28 Gewichtsteile beträgt, der Gehalt an Na_2O 13-25 Gewichtsteile beträgt, der Gehalt an K_2O 6-15 Gewichtsteile beträgt, der Gehalt an MgO 7-16 Gewichtsteile beträgt und der Gehalt an ZrO_2 0,1-5 Gewichtsteile beträgt, bezogen auf 100 Gewichtsteile von SiO_2 ;

und wobei die Glaszusammensetzung einen M-Wert von 5-13 hat, wie durch die folgende Formel (1) berechnet:

$$M = P_1 \cdot \text{wt}(\text{Na}_2\text{O}) + P_2 \cdot \text{wt}(\text{K}_2\text{O}) + P_3 \cdot \text{wt}(\text{MgO}) + P_4 \cdot \text{wt}(\text{ZrO}_2) - P_5 \cdot \text{wt}(\text{Al}_2\text{O}_3) \quad (1)$$

wobei $\text{wt}(\text{Na}_2\text{O})$ für den Gewichtsteil von Na_2O bezogen auf 100 Gewichtsteile von SiO_2 steht, $\text{wt}(\text{K}_2\text{O})$ für den Gewichtsteil von K_2O bezogen auf 100 Gewichtsteile von SiO_2 steht, $\text{wt}(\text{MgO})$ für den Gewichtsteil von MgO bezogen auf 100 Gewichtsteile von SiO_2 steht, $\text{wt}(\text{ZrO}_2)$ für den Gewichtsteil von ZrO_2 bezogen auf 100 Gewichtsteile von SiO_2 steht, und $\text{wt}(\text{Al}_2\text{O}_3)$ für den Gewichtsteil von Al_2O_3 bezogen auf 100 Gewichtsteile von SiO_2 steht; und wobei P_1 einen Wert von 0,53 hat, P_2 einen Wert von 0,153 hat, P_3 einen Wert von 0,36 hat, P_4 einen Wert von 0,67 hat und P_5 einen Wert von 0,018 hat.

2. Die Glaszusammensetzung nach Anspruch 1, wobei der Wert von M 6-10 beträgt, weiter bevorzugt der Wert von M 6,5-9 beträgt und weiter bevorzugt 7-8 beträgt.
3. Die Glaszusammensetzung nach Anspruch 1 oder 2, wobei der Gehalt an Al_2O_3 18-25 Gewichtsteile beträgt, der Gehalt an Na_2O 17-23 Gewichtsteile beträgt, der Gehalt an K_2O 7-12 Gewichtsteile beträgt, der Gehalt an MgO 8-14 Gewichtsteile beträgt und der Gehalt an ZrO_2 0,8-2 Gewichtsteile beträgt, bezogen auf 100 Gewichtsteile von SiO_2 .
4. Die Glaszusammensetzung nach Anspruch 1 oder 2, wobei die Glaszusammensetzung ferner eine bestimmte Menge an SrO umfasst, wobei der Gehalt an SrO 0-3 Gewichtsteile, vorzugsweise weniger als 0,6 Gewichtsteile, bezogen auf 100 Gewichtsteile von SiO_2 , beträgt.
5. Die Glaszusammensetzung nach Anspruch 1 oder 2, wobei die Glaszusammensetzung ferner BaO und CaO umfasst, wobei der Gehalt an BaO 0-2 Gewichtsteile, vorzugsweise weniger als 0,5 Gewichtsteile, beträgt und der Gehalt an CaO 0-2 Gewichtsteile, vorzugsweise weniger als 0,5 Gewichtsteile, bezogen auf 100 Gewichtsteile von SiO_2 , beträgt.

6. Die Glaszusammensetzung nach Anspruch 1, wobei die Glaszusammensetzung eine Korrosionsmenge von 10 % HF-Säure/20 °C/20 min von weniger als 38 mg/cm² hat.
7. Die Glaszusammensetzung nach Anspruch 1, wobei die Glaszusammensetzung einen Youngschen Modul von mehr als 65 GPa, weiter bevorzugt mehr als 75 GPa hat.
8. Eine Glasplatte, **dadurch gekennzeichnet, dass** die Glasplatte aus der Glaszusammensetzung nach einem der Ansprüche 1 bis 7 hergestellt ist.
9. Die Glasplatte nach Anspruch 8, wobei das Verhältnis eines Oberflächendruckspannungswerts in einer Tiefe von 3 µm der Glasplatte zu dem in einer Tiefe von 7 µm und die Dicke einer Druckspannungsschicht durch die folgende Formel (2) berechnet werden, und der resultierende Wert des Risswiderstandsfaktors K kleiner als 8 sein sollte:

$$K = Q_1 \cdot (x/y)^2 + Q_2 \cdot (x/y) - Q_3 \cdot d/10 \quad (2)$$

wobei x der Oberflächendruckspannungswert in einer Tiefe von 3 µm der Glasplatte ist und y der Oberflächendruckspannungswert in einer Tiefe von 7 µm der Glasplatte in Einheit von MPa ist; und d für die Dicke einer Druckspannungsschicht in Einheit von µm steht;

wobei Q₁ einen Wert von 3,5, Q₂ einen Wert von 1,8 und Q₃ einen Wert von 0,12 hat.

10. Die Glasplatte nach Anspruch 9, wobei der Wert von K kleiner als 7,7, weiter bevorzugt kleiner als 7,3 ist.
11. Ein Verfahren zur Herstellung der Glasplatte nach einem der Ansprüche 8 bis 10, **dadurch gekennzeichnet, dass** die Glaszusammensetzung nach einem der Ansprüche 1 bis 7 zu einem plattenförmigen Erzeugnis hergestellt und einer chemischen Verstärkung unterzogen wird,

wobei die chemische Verstärkung das Eintauchen des plattenförmigen Erzeugnisses in ein geschmolzenes Salz eines Nitrats umfasst,
wahlweise, das Eintauchen des plattenförmigen Erzeugnisses in ein geschmolzenes Salz von Natriumnitrat (NaNO₃), ein geschmolzenes Salz von Kaliumnitrat (KNO₃) oder ein gemischtes geschmolzenes Salz davon umfasst;
wahlweise, zuerst das Eintauchen des plattenförmigen Erzeugnisses in ein geschmolzenes Salz von Natriumnitrat (NaNO₃) und dann das Eintauchen in ein geschmolzenes Salz von Kaliumnitrat (KNO₃) umfasst.
12. Das Herstellungsverfahren nach Anspruch 11, wobei während der chemischen Verstärkung die Temperatur des geschmolzenen Salzes 380 °C-450 °C, vorzugsweise 390 °C-420 °C und noch bevorzugter 400 °C beträgt und die Eintauchzeit 0,3-9 Stunden, vorzugsweise 1-8 Stunden, weiter bevorzugt 2-7 Stunden, weiter bevorzugt 3-6 Stunden und noch bevorzugter 4-5 Stunden beträgt.
13. Das Herstellungsverfahren nach Anspruch 12, wobei eine Ultraschallbehandlung während der chemischen Verstärkung hinzugefügt wird.
14. Das Herstellungsverfahren nach Anspruch 13, wobei die Ultraschallwelle bei der Ultraschallbehandlung eine durchschnittliche Schallenergiedichte von 50-60 W/L und eine Ultraschallfrequenz von 25-40 kHz hat.
15. Das Herstellungsverfahren nach Anspruch 13, wobei die Temperatur der Ultraschallbehandlung 380 °C-425 °C, vorzugsweise 390 °C-410 °C beträgt; und wobei die Behandlungszeit 10-80 min, vorzugsweise 15-50 min und noch bevorzugter 20-40 min beträgt.
16. Das Herstellungsverfahren nach Anspruch 13, wobei die Ultraschallbehandlung in Abständen durchgeführt wird, wobei das Zeitintervall zwischen den Ultraschallbehandlungen 1-40 min, vorzugsweise 3-35 min und noch bevorzugter 5-20 min beträgt; und wobei die Ultraschallbehandlungszeit jedes Mal 10-80 min, vorzugsweise 15-50 min und noch bevorzugter 20-40 min beträgt.
17. Das Herstellungsverfahren nach Anspruch 13, wobei während des Durchführens der chemischen Verstärkung Mikrowellenstrahlung auf die Oberfläche des Glases angewendet wird, vorzugsweise abwechselnd mit der Ultraschallbehandlung durchgeführt wird.

18. Das Herstellungsverfahren nach Anspruch 17, wobei der Frequenzbereich der Mikrowelle 1,1-6,2 GHz, vorzugsweise 2,6-4,6 GHz, noch bevorzugter 3,0-4,0 GHz und am meisten bevorzugt 3,3-3,5 GHz ist.
19. Das Herstellungsverfahren nach Anspruch 17, wobei die Dauer der Anwendung der Mikrowelle 5-60 min, vorzugsweise 10-40 min und am meisten bevorzugt 12-25 min beträgt, wobei das Zeitintervall der Anwendung der Mikrowelle 2-30 min, vorzugsweise 5-20 min und noch bevorzugter 7-15 min beträgt; und wobei die Dauer der Anwendung der Mikrowelle jedes Mal 5-60 min, vorzugsweise 10-40 min und am meisten bevorzugt 12-25 min beträgt.

Revendications

1. Une composition de verre, comprenant SiO_2 , Al_2O_3 , Na_2O , K_2O , MgO et ZrO_2 ,

dans laquelle la teneur en Al_2O_3 est de 15 à 28 parties en poids, la teneur en Na_2O est de 13 à 25 parties en poids, la teneur en K_2O est de 6 à 15 parties en poids, la teneur en MgO est de 7 à 16 parties en poids, et la teneur en ZrO_2 est de 0,1 à 5 parties en poids, par rapport à 100 parties en poids de SiO_2 ;
et dans lequel la composition de verre a une valeur M de 5 à 13, telle que calculée par la formule suivante (1) :

$$M = P_1 \cdot \text{wt}(\text{Na}_2\text{O}) + P_2 \cdot \text{wt}(\text{K}_2\text{O}) + P_3 \cdot \text{wt}(\text{MgO}) + P_4 \cdot \text{wt}(\text{ZrO}_2) - P_5 \cdot \text{wt}(\text{Al}_2\text{O}_3) \quad (1)$$

dans laquelle $\text{wt}(\text{Na}_2\text{O})$ représente la partie en poids de Na_2O par rapport à 100 parties en poids de SiO_2 ,
 $\text{wt}(\text{K}_2\text{O})$ représente la partie en poids de K_2O par rapport à 100 parties en poids de SiO_2 ,
 $\text{wt}(\text{MgO})$ représente la partie en poids de MgO par rapport à 100 parties en poids de SiO_2 ,
 $\text{wt}(\text{ZrO}_2)$ représente la partie en poids de ZrO_2 par rapport à 100 parties en poids de SiO_2 , et
 $\text{wt}(\text{Al}_2\text{O}_3)$ représente la partie en poids de Al_2O_3 par rapport à 100 parties en poids de SiO_2 ;
et dans laquelle P_1 a une valeur de 0,53, P_2 a une valeur de 0,153, P_3 a une valeur de 0,36, P_4 a une valeur de 0,67 et P_5 a une valeur de 0,018.

2. La composition de verre selon la revendication 1, dans laquelle la valeur de M est de 6 à 10, de préférence encore la valeur de M est de 6,5 à 9, et de préférence encore de 7 à 8.
3. La composition de verre selon la revendication 1 ou 2, dans laquelle la teneur en Al_2O_3 est de 18 à 25 parties en poids, la teneur en Na_2O est de 17 à 23 parties en poids, la teneur en K_2O est de 7 à 12 parties en poids, la teneur en MgO est de 8 à 14 parties en poids, et la teneur en ZrO_2 est de 0,8 à 2 parties en poids, par rapport à 100 parties en poids de SiO_2 .
4. La composition de verre selon la revendication 1 ou 2, dans laquelle ladite composition de verre comprend en outre une certaine quantité de SrO , la teneur en SrO étant de 0 à 3 parties en poids, de préférence moins de 0,6 partie en poids, par rapport à 100 parties en poids de SiO_2 .
5. La composition de verre selon la revendication 1 ou 2, dans laquelle ladite composition de verre comprend en outre du BaO et du CaO , la teneur en BaO étant de 0 à 2 parties en poids, de préférence inférieure à 0,5 partie en poids, et la teneur en CaO étant de 0 à 2 parties en poids, de préférence inférieure à 0,5 partie en poids, par rapport à 100 parties en poids de SiO_2 .
6. La composition de verre selon la revendication 1, dans laquelle ladite composition de verre a une quantité de corrosion de 10% d'acide HF/20°C/20 min inférieure à 38 mg/cm².
7. La composition de verre selon la revendication 1, dans laquelle ladite composition de verre a un module de Young supérieur à 65 GPa, de préférence encore supérieur à 75 GPa.
8. Une plaque de verre, caractérisée en ce que ladite plaque de verre est fabriquée à partir de la composition de verre selon l'une quelconque des revendications 1 à 7.
9. La plaque de verre selon la revendication 8, dans laquelle le rapport d'une valeur de contrainte de compression de surface à une profondeur de 3 μm de ladite plaque de verre à celle à une profondeur de 7 μm, et l'épaisseur d'une

couche de contrainte de compression sont calculés par la formule suivante (2), et la valeur résultante du facteur de résistance aux fissures K doit être inférieure à 8 :

$$K = Q_1 * (x/y)^2 + Q_2 * (x/y) - Q_3 * d/10 \quad (2)$$

dans laquelle x est la valeur de contrainte de compression de surface à une profondeur de 3 µm de la plaque de verre, et y est la valeur de contrainte de compression de surface à une profondeur de 7 µm de la plaque de verre, en unité de MPa ; et d représente l'épaisseur d'une couche de contrainte de compression, en unité de µm ; dans laquelle Q₁ a une valeur de 3,5, Q₂ a une valeur de 1,8 et Q₃ a une valeur de 0,12.

10. La plaque de verre selon la revendication 9, dans laquelle la valeur de K est inférieure à 7,7, de préférence encore inférieure à 7,3.

11. Un procédé de préparation de la plaque de verre selon l'une quelconque des revendications 8 à 10, **caractérisé en ce que** la composition de verre selon l'une quelconque des revendications 1 à 7 est fabriquée comme un article en forme de plaque et soumise à un renforcement chimique,

dans lequel ledit renforcement chimique comprend immerger l'article en forme de plaque dans un sel fondu d'un nitrate,

facultativement, immerger ledit article en forme de plaque dans un sel fondu de nitrate de sodium (NaNO₃), un sel fondu de nitrate de potassium (KNO₃), ou un sel fondu mélangé de ceux-ci ;

facultativement, immerger d'abord ledit article en forme de plaque dans un sel fondu de nitrate de sodium (NaNO₃), puis l'immerger dans un sel fondu de nitrate de potassium (KNO₃).

12. Le procédé de préparation selon la revendication 11, dans lequel pendant le renforcement chimique, la température du sel fondu est de 380 °C à 450 °C, de préférence de 390 °C à 420 °C, et plus préférablement de 400 °C, et le temps d'immersion est de 0,3 à 9 heures, de préférence de 1 à 8 heures, de préférence encore de 2 à 7 heures, de préférence encore de 3 à 6 heures, et plus préférablement de 4 à 5 heures.

13. Le procédé de préparation selon la revendication 12, dans lequel un traitement par ultrasons est ajouté pendant le renforcement chimique.

14. Le procédé de préparation selon la revendication 13, dans lequel l'onde ultrasonore dans ledit traitement par ultrasons a une densité d'énergie acoustique moyenne de 50 à 60 W/L et une fréquence ultrasonore de 25 à 40 kHz.

15. Le procédé de préparation selon la revendication 13, dans lequel la température dudit traitement par ultrasons est de 380 °C à 425 °C, de préférence de 390 °C à 410 °C ; et le temps de traitement est de 10 à 80 min, de préférence de 15 à 50 min, et plus préférablement de 20 à 40 min.

16. Le procédé de préparation selon la revendication 13, dans lequel ledit traitement par ultrasons est effectué à des intervalles, dans lequel l'intervalle de temps entre les traitements par ultrasons est de 1 à 40 min, de préférence de 3 à 35 min, et plus préférablement de 5 à 20 min ; et le temps de traitement par ultrasons à chaque fois est de 10 à 80 min, de préférence de 15 à 50 min, et plus préférablement de 20 à 40 min.

17. Le procédé de préparation selon la revendication 13, dans lequel lors de la réalisation du renforcement chimique, du rayonnement micro-ondes est appliqué à la surface du verre, de préférence réalisé en alternance avec le traitement par ultrasons.

18. Le procédé de préparation selon la revendication 17, dans lequel la plage de fréquences des micro-ondes est de 1,1 à 6,2 GHz, de préférence de 2,6 à 4,6 GHz, plus préférablement de 3,0 à 4,0 GHz, et le plus préférablement de 3,3 à 3,5 GHz.

19. Le procédé de préparation selon la revendication 17, dans lequel la durée d'application du micro-ondes est de 5 à 60 min, de préférence de 10 à 40 min, et le plus préférablement de 12 à 25 min, dans lequel l'intervalle de temps d'application du micro-ondes est de 2 à 30 min, de préférence de 5 à 20 min, et plus préférablement de 7 à 15 min ; et la durée d'application du micro-ondes à chaque fois est de 5 à 60 min, de préférence de 10 à 40 min, et le plus préférablement de 12 à 25 min.

REFERENCES CITED IN THE DESCRIPTION

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